Re: Tamar Elsawy et al.

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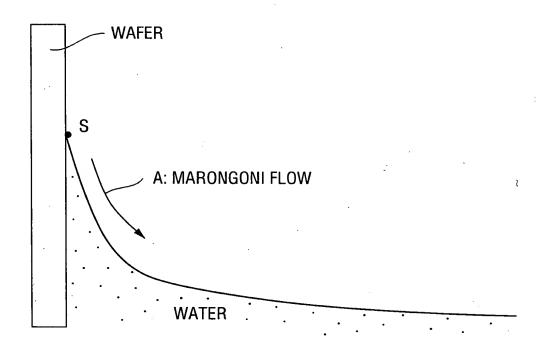
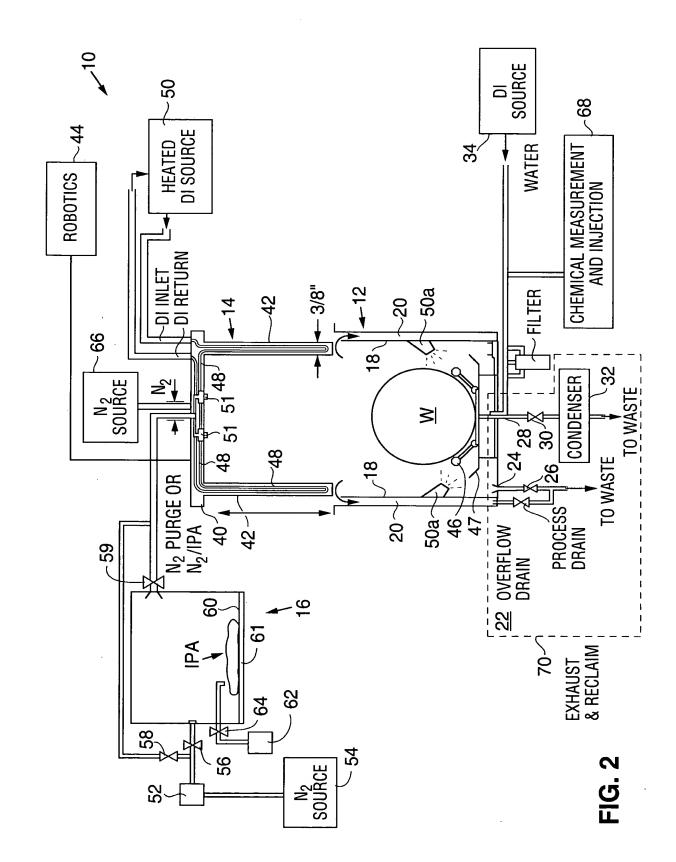
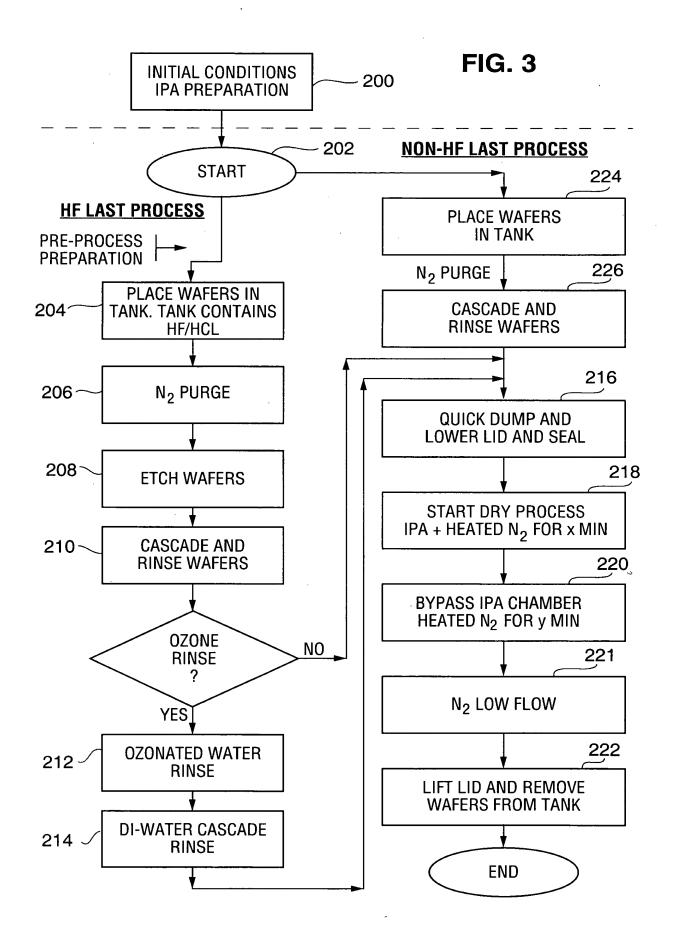


FIG. 1 (PRIOR ART)

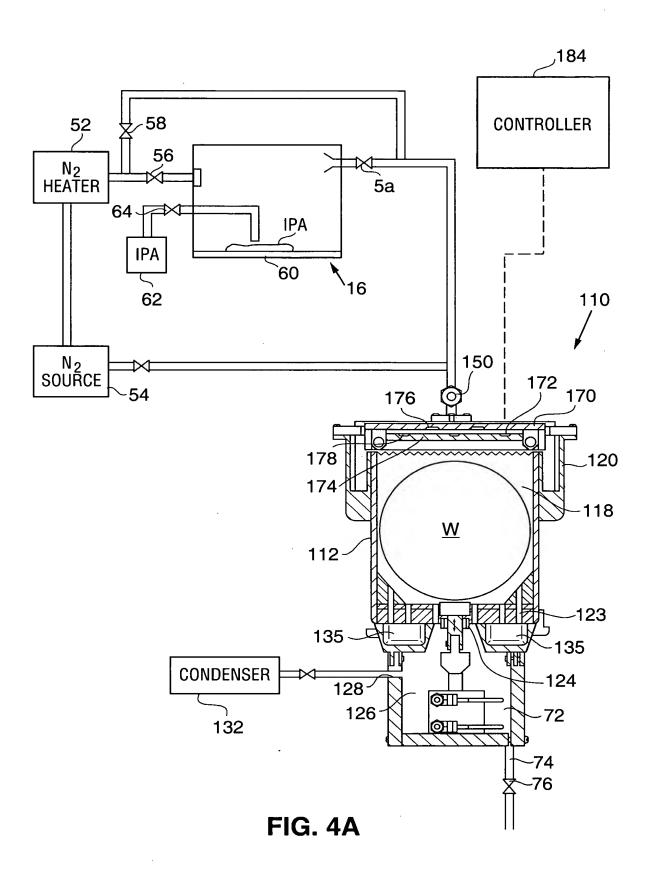
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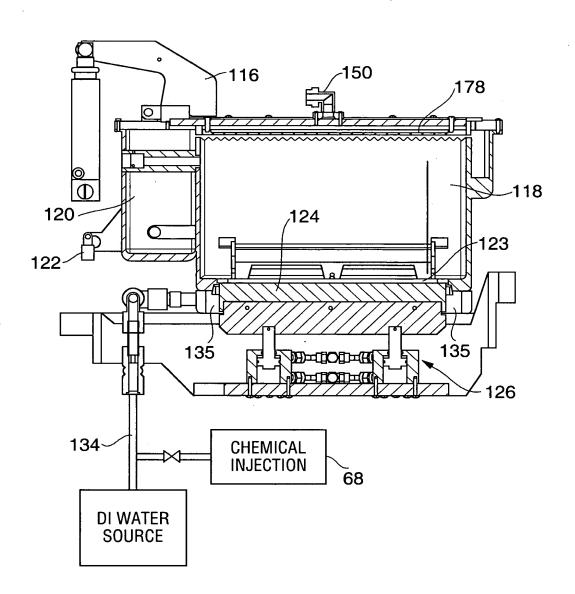


FIG. 4B

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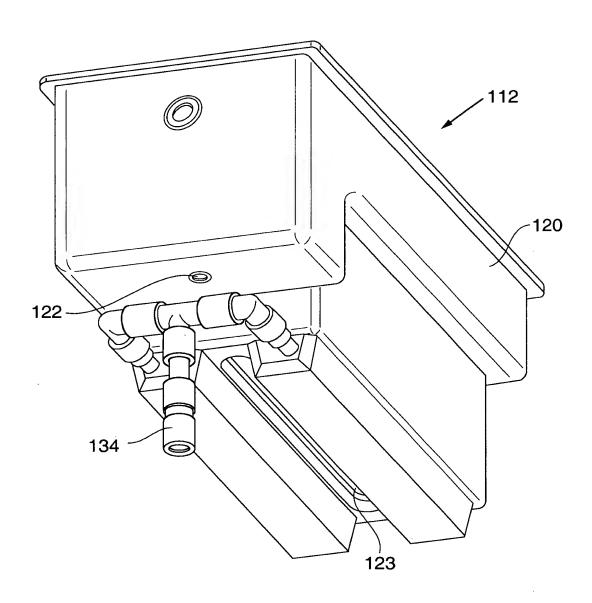


FIG. 4C

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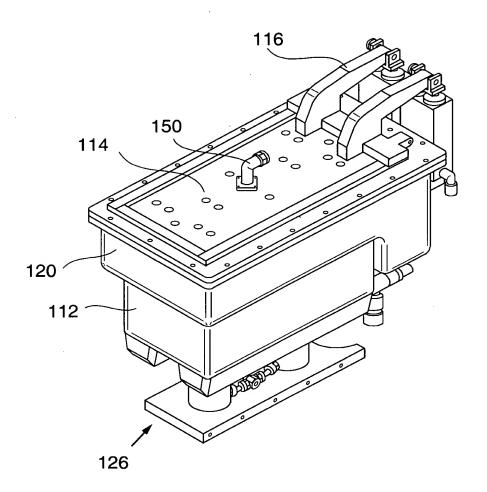
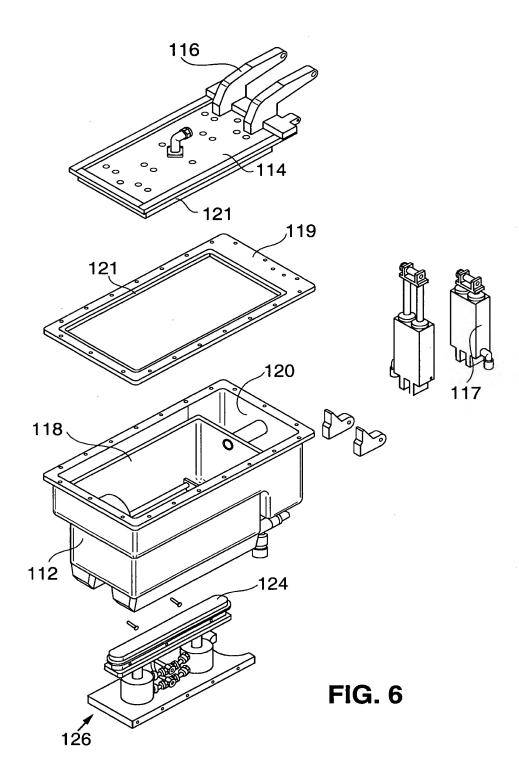


FIG. 5

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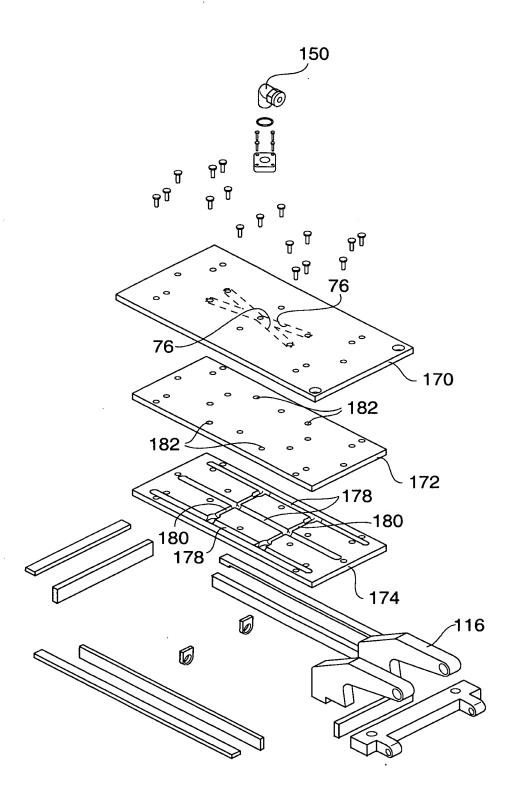
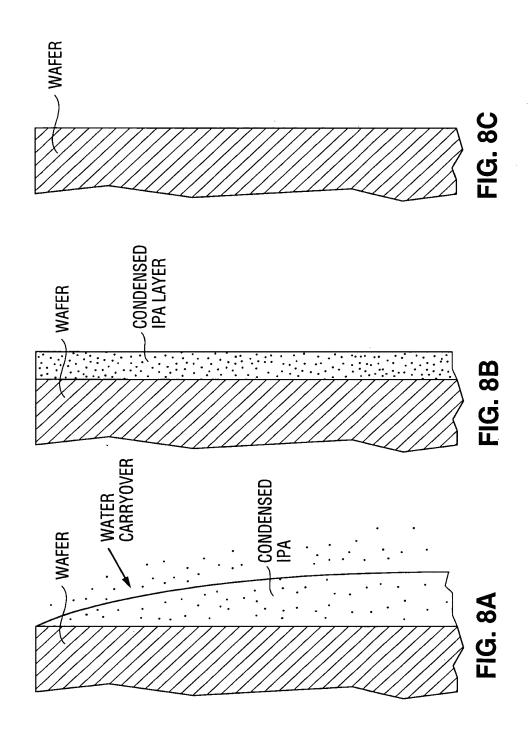
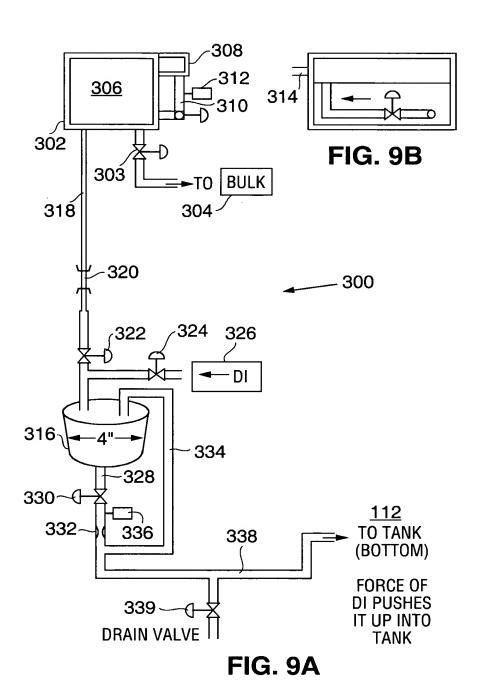


FIG. 7

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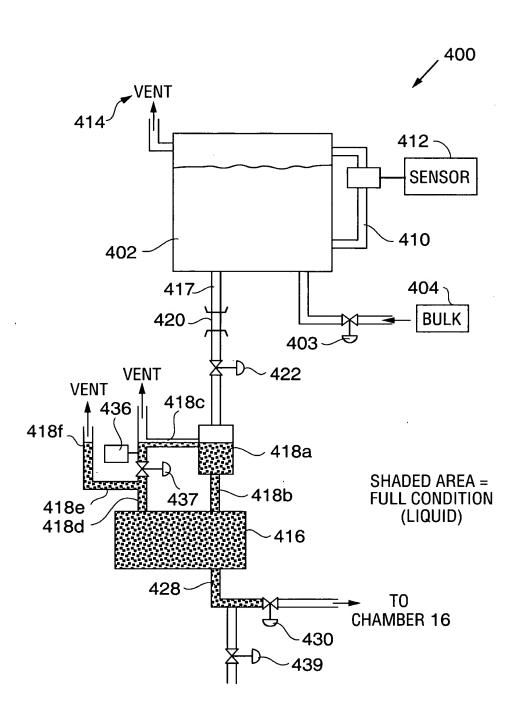


FIG. 10